Prognostics for Electronics Components of Avionics Systems

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Abstract—Electronics components have and increasingly critical role in avionics systems and for the development of future aircraft systems. Prognostics of such components is becoming a very important research filed as a result of the need to provide aircraft systems with system level health management. This paper reports on a prognostics application for electronics components of avionics systems, in particular, its application to the Isolated Gate Bipolar Transistor (IGBT). The remaining useful life prediction for the IGBT is based on the particle filter framework, leveraging data from an accelerated aging tests on IGBTs. The accelerated aging test provided thermal-electrical overstress by applying thermal cycling to the device. In-situ state monitoring, including measurements of the steady-state voltages and currents, electrical transients, and thermal transients are recorded and used as potential precursors of failure. [1,2]

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1. INTRODUCTION

Predicting the remaining useful life (RUL) of electronic components like MOSFETs, BJTs, and IGBTs is one of the most challenging frontiers of Prognostic Health Management (PHM) systems. Such components form the backbone of avionics systems that play an ever-increasing critical role in on-board, autonomous functions for vehicle controls, communications, navigation, and radar systems.

During high-voltage operation, large internal electrical fields build up within power devices, which can increase the rate of degradation. For prognostic purposes the externally observable characteristics of the device, such as measurements of the collector current/voltage during duty cycle on/off states of the IGBT/power-FET that show degradation trends towards thermal runaway or latch-up, are correlated to physics-of-failure mechanisms like hot carrier injection, electro-migration, etc., and used in a particle filtering (PF) framework to carry out RUL prediction.

This prognostic exercise demonstrates the feasibility of detecting failure precursors in semiconductor device behavior and using them in an intelligent prediction framework to derive RUL estimates. The fact that the particle filer algorithm provides a RUL probability distribution (pdf), instead of a single Mean-Time-Between-Failure (MTBF) value, makes the interpretation of the prognostic result more useful and intuitive.

2. BACKGROUND

The research in prognostics of IGBTs has been approached from different angles. A study of failure precursors for prognostics has been presented in [1]. This work focused on devices that had been aged under thermal overstress and identified precursors of failure that could be measured and computed from external signals. An accelerated aging, characterization and operational scenario simulation system was presented in [2]. This system allows the aging under different operational conditions providing thermal and electrical overstress to devices, while monitoring in-situ key operational parameters that could serve as precursors of failure. The development of physics based models of aging

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[2] IEEEAC paper # 1337, Version 3, Updated November 2, 2008

and fault progression has also been considered. The work presented in [3] focuses on modeling the aging effects at a system level, by studying electrical power drivers using IGBTs.

Failure Mechanisms Review

Some major intrinsic faults, relevant to the transistor physics, include dielectric breakdown, hot carrier injection, and electromigration [4, 5]. Some major extrinsic faults, relevant to the transistor packaging, include contact migration, wire lift, die solder degradation and package delamination [4, 6].

Dielectric breakdown occurs when a strong electric field induces a current channel through a previously insulated medium. Acute dielectric breakdown is typically the result of electrostatic discharge (ESD) and junction over-voltage. Time Dependent Dielectric Breakdown (TDDB) refers to the breakdown of gate oxide caused by chronic defect accumulation in the SiO2 insulator. TDDB is shown to be advanced by increases in electric field strength [5]. A strong electric field may impart energy into an electron or a hole which then becomes a so *"hot carrier"* due to the high kinetic energy [4]. Hot carriers have sufficient energy to tunnel and become trapped in gate oxide, and they are the primary cause of TDDB and contribute to device failures under normal operating conditions. *Electromigration* is a result of high current densities in silicon interconnects causing migration of metals. Formation of metal voids on interconnects can cause open circuits or high resistive paths, which in turn can result in poor performance or circuit malfunction [5].

Contact migration forms metal voids between external contact metals and the silicon. As metal voids grow, the aluminum or other metals can diffuse down to the silicon. This in turn can cause metal spikes to form deep in the silicon region which results in shorting the p-n junctions [7]. *Wire lift* occurs when the bond between the package wires connecting to the silicon die fail. Wire lift has been identified as a dominant failure mode in high power IGBTs [6]. *Die solder degradation* is another prominent package related fault. Solder attaching the silicon die and package heatsink develop cracks and voids due to thermal expansion mismatch between materials during expansion and contraction [6, 8].

Accelerated Aging Methodologies

Thermal stress and electrical stress are the most common aging methodologies. Thermal cycling and chronic temperature overstress are prevalent thermal stress methods, with thermal cycling among the most prevalent accelerated aging methodology in electronics. Thermal cycling subjects devices to rapid changes in temperature differentials causing thermal expansion and contraction. Die solder degradation and wire lift are associated strongly with this aging method. Thermal overstress, another prevalent method, subjects devices to high temperatures for extended periods of time. TDDB is accelerated under high temperatures [9] and transistors have exhibited temperature dependant lifetimes accelerated by this mechanism [10]. IGBTs aged with self heating have shown changes in current ringing characteristics during switching [3].

Electrical overstress can be induced though transient and steady-state methods. Transient methods include electro static discharge (ESD), inductive switching and electromagnetic pulses. ESD is a leading cause of gate oxide failure [11] and hard switching of inductive loads, causes voltage spikes which can cause significant damage to drain-source junctions [12]. Steady-state methods include chronic over-voltage and over-current. Applying high gate voltages [13], setting gate voltage (V_g) to maximize drain current [14], and applying current overstress across the drain [15] have been shown to induce hot carrier and TBBD [9].

3. REMAINING USEFUL LIFE (RUL)

Particle filtering is a sequential Monte Carlo (SMC) technique for implementing a recursive Bayesian filter using Monte Carlo (MC) simulations. It is primarily used for state estimation and tracking. The mathematical formulation for PF methods have been discussed in [16]. The basic idea is to develop a nonparametric representation of the system state pdf in the form of a set of particles with associated importance weights. The particles are sampled values from the unknown state space and the weights are the corresponding discrete probability masses. As the filter iterates the particles are propagated according to the system state transition model, while their weights are updated based upon the likelihoods of the measurement given the particle values. Resampling of the particle distribution is done when needed in order to prevent the degeneracy of the weights. For state prediction purposes the same PF framework can be used by running only the model-based particle propagation step until the predicted state value crosses some predetermined end-of-life (EOL) threshold. The predicted trajectory of each particle then generates an estimate of RUL, which can be combined with the associated weights to give the RUL pdf. The process is broken down into an offline (learning) and an online (tracking and prediction) part. During offline analysis, regression is performed to find representative ageing curves. Exponential growth models, as shown in Eqn. 1, are then fitted on these curves to identify the relevant decay parameters like C and λ:

$$\theta = C\exp(-\lambda t) \qquad (1)$$

where θ is an internal model parameter of interest. More details of the PF framework used here can be found in [17].

The state and measurement equations that describe the

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semiconductor aging model are given below:

$$z_k = z_{k-1}.\exp\{-\Lambda_k(t_k-t_{k-1})\}+ \omega_k$$
$$\Lambda_k = \Lambda_{k-1} + v_k$$
$$x_k = [z_k ; \Lambda_k]$$
$$y_k = z_k + v_k \tag{2}$$

where the vector **z**, in our case, consists of the off state exponential time decay constants for the IGBT collector current (I_{CE}), and matrices **C** and **Λ** contain their aging decay parameters C and λ values respectively. The **z** and **Λ** vectors are combined to form the state vector **x**. The measurement vector **y** comprises the time decay parameters inferred from measured data. The time index is denoted by k. The values of the **C** and **Λ** vectors learnt from regression can used to initialize the particle filter. The noise samples ω, v and v are picked from zero mean Gaussian distributions whose standard deviations are derived from the given training data, thus accommodating for the sources of uncertainty in feature extraction, regression modeling and measurement. System importance resampling of the particles is carried out in each iteration so as to reduce the degeneracy of particle weights. This helps in maintaining track of the state vector even under the presence of disruptive effects like unmodeled operational conditions (in our case, high temperatures).

The system description model developed in the offline process is fed into the online process where the particle filtering prognosis framework is triggered by a diagnostic routine. The algorithm incorporates the model parameter as an additional component of the state vector and thus, performs parameter identification in parallel with state estimation. Predicted values of the time decay parameters are compared against end-of-life thresholds to derive EOL/RUL estimates. Figure 1 shows a simplified schematic of the process described above.
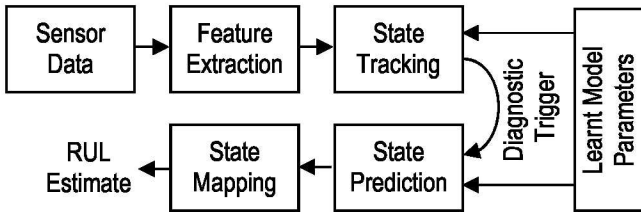

Figure 1 – Particle Filter Framework

4. EXPERIMENT DETAILS

The IGBT behaves essentially like a MOSFET and a BJT connected in a Darlington configuration. The input of the IGBT is modeled by the MOSFET, while the output is modeled by a BJT. As a combination of these two devices the IGBT takes on their characteristics as well as some additional ones caused by their interaction. For example, it exhibits a tail current while turning off which is modeled by

a decaying current flowing through the BJT after the MOSFET has been turned off. This is shown in Figure 2.
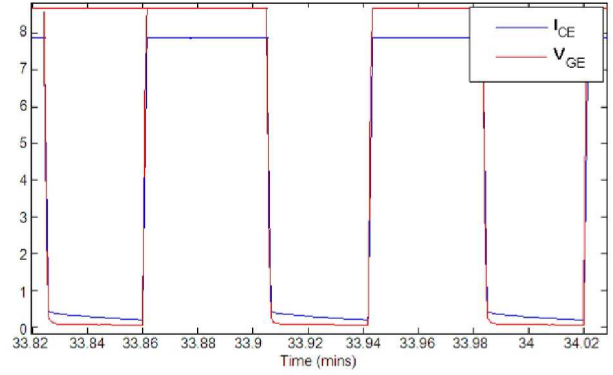

Figure 2 – IGBT Voltage and Current Waveforms

At high temperature thermal cycling these current decay curves change due to hot carrier injection. The trends in these curve shifts can act as a precursor to catastrophic latch-up and subsequent thermal runaway conditions. Figure 3(a)-(c) shows the shift in the off-state current decay as aging progresses, finally ending in a latch-up condition as shown in Figure 3(d).
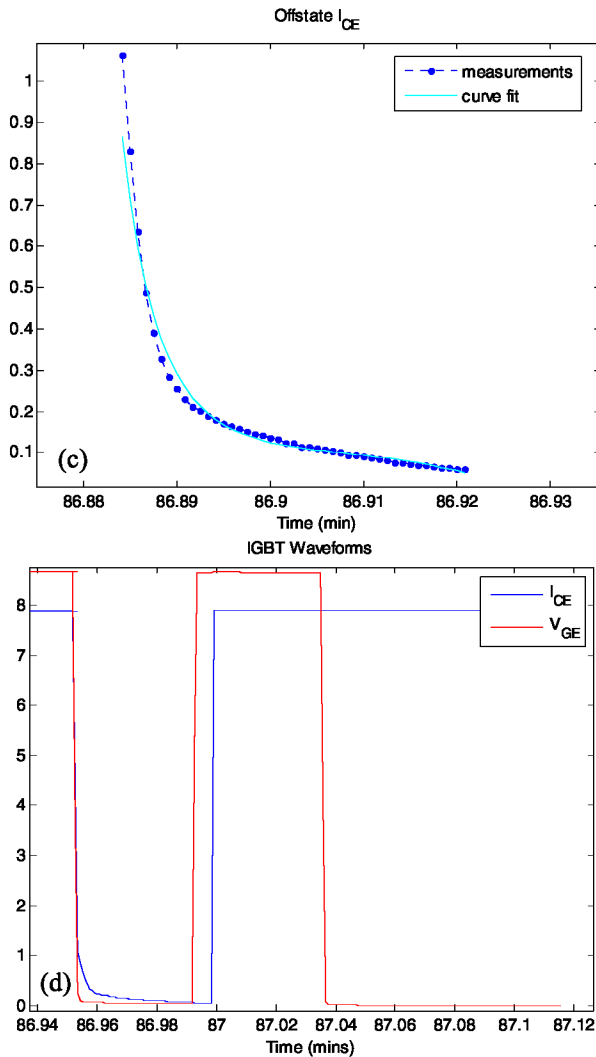

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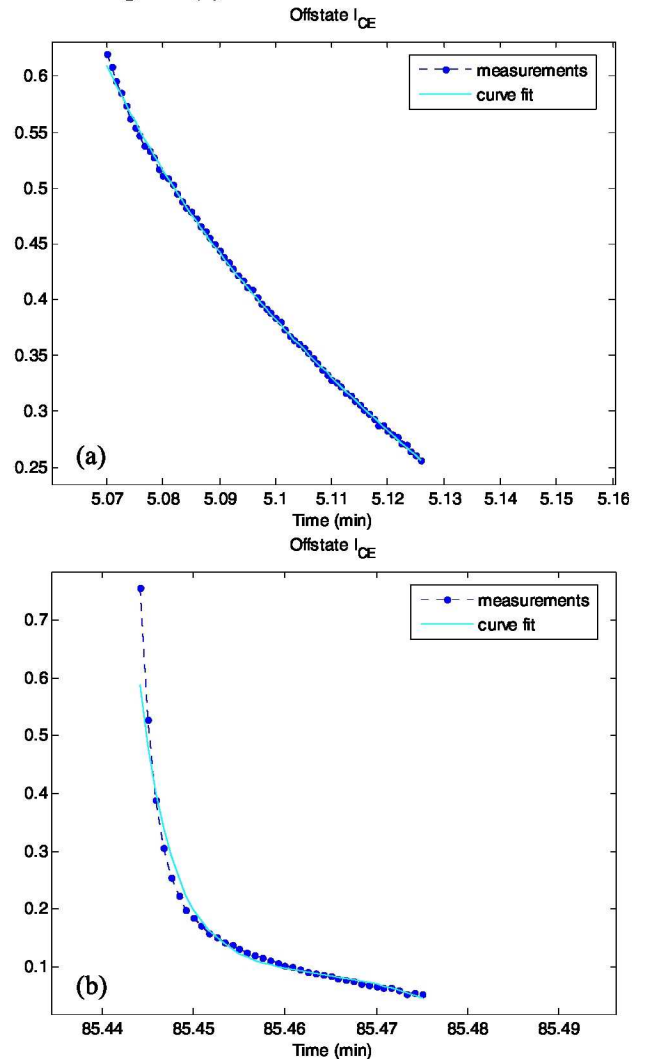
Figure 3 – (a), (b) and (c) Shift in IGBT Off-state Current Decay with Aging; (d) Latch-up Condition

Accelerated Aging Settings

Thermal overstress accelerated aging was conducted on IGBTs using the agile accelerated aging, characterization and scenario simulation system for gate controlled power transistors presented in [2]. An International Rectifier IRG4BC30KD IGBT with a 600V/15A current rating in a TO220 package was attached to the transistor test board with no external heatsink. The collector-emitter junction was connected in series with a load power supply and a 0.2Ω load resistor. A 50Ω resistor was placed between the gate driver and the IGBT gate for current measurement. An infrared sensor was attached to the IGBT case for temperature measurement. The gate signal was chosen to be a Pulse Width Modulated signal with amplitude of 10V, frequency of 10 KHz and a duty cycle of 40%. The aging process was controlled by a hysteresis temperature controller with set points of 268°C and 270°C, switching the gate voltage ON and OFF as a control action. The load power supply voltage was 10V which resulted in a current of 8A. An additional temperature threshold controller, with a set point of 305°C, was programmed to turn off the load

power supply and end the experiment in the event of thermal runaway and latching failures. The IGBT under consideration was aged for ~210 minutes until latch-up resulting on thermal runaway.

5. RESULTS

During the model learning process, we extract the tail current sections from the I_{CE} waveform, transform them to the *log* domain and then fit 3rd order polynomials, as expressed below:

$$I_{CE}(t) = \exp\{P_1 t^3 + P_2 t^2 + P_3 t + P_4\}. \quad (3)$$

The equivalent fits in the time domain are denoted by the cyan lines in Figure 3(a)-(c). The fit parameters P_1, P_2, P_3 and P_4 are then tracked over the entire aging duration. It is to be noted that the parameters are highly correlated with each other (as denoted by the correlation coefficient matrix shown below in Eqn. 4), and consequently, we use only P_1 as the parameter to track.

$$\rho = \begin{bmatrix} 1.0000 & -0.9964 & 0.9873 & -0.9747 \\ -0.9964 & 1.0000 & -0.9972 & 0.9899 \\ 0.9873 & -0.9972 & 1.0000 & -0.9978 \\ -0.9747 & 0.9899 & -0.9978 & 1.0000 \end{bmatrix}. \quad (4)$$
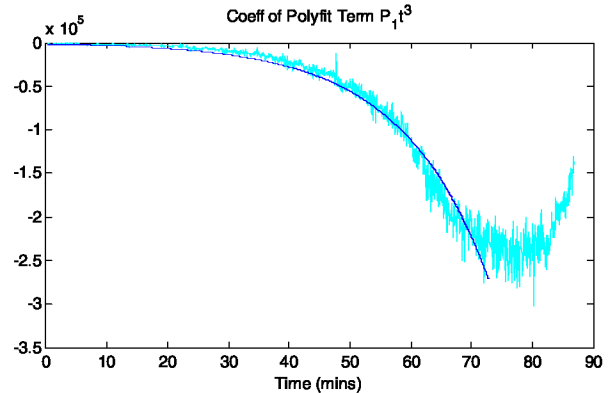

Figure 4 – Trending of Curve Fit Parameter P_1

Overall, the parameter shows an exponential growth rate (negative) as shown in Figure 4, indicating an Arrhenius aging process perhaps. Near the end, the curve shows some anomalous behavior as the IGBT approaches the latch-up condition. Originally the Arrhenius equation described the temperature dependence of the rate of a chemical reaction. Currently it is perceived largely as a empirical relation which can be used to model the temperature variance of many thermally-induced processes.

For running the particle filter framework, we use an exponential growth model for P_1 like the one shown in equation 2. Since we do not have separate learning and testing datasets, we do not use the regressed C and λ values from the model learning process to jump start our PF algorithm. Instead, we use 0 and 1 as the initial values for P_1

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and λ_{P_1}. The EOL threshold is chosen as -2.5x10^5, which is approximately the value of P_1 at the end of its exponential behavior. The prediction time is arbitrarily chosen to be 51.875 minutes.

Figure 5 shows the performance of the PF in tracking and prediction modes. The inset plot shows the λ_{P_1} parameter estimation. After the prediction timeline, the mean of the last 100 λ_{P_1} values is used for the propagation of each particle according to the state transition model (first line in equation 3). No more computed P_1 values are used to update the particle weights. The propagated particle values are compared against the EOL threshold to compute the distribution of EOL times. A mixture of Gaussians is then fitted in a least square sense to these EOL values to plot the magenta EOL pdf. The RUL pdf is simple the prediction time subtracted from the EOL pdf. It is to be noted that despite the generic initial particle values, modeling uncertainties and system noise, the PF performance is very good.

6. CONCLUSIONS

This prognostic exercise demonstrates the feasibility of detecting failure precursors in semiconductor device behavior and using them in an intelligent prediction framework (e.g. particle filtering) to derive RUL estimates. The fact that the PF provides a RUL pdf, instead of a single Mean-Time-Between-Failure (MTBF) value, makes the interpretation of the prognostic result more useful and intuitive.

The results presented here incorporate simple exponential growth models to explain the aging behavior of IGBTs. Although the prediction results are very good, such an approach has limitations in trying to apply the aging parameters and EOL thresholds learnt from one device to another. In order to achieve that, we need to explicitly derive physics-of-failure based aging models, identify their parameters from externally observable device characteristics and then use those models in a PF framework to carry out prognostics. In such a case, aging behavior will be linked to the changes in the internal model parameters which can then be tied to failure mechanisms like hot carrier injection, electro-migration etc. The focus of our future work will be to devise aging experiments to fulfill the above objectives.

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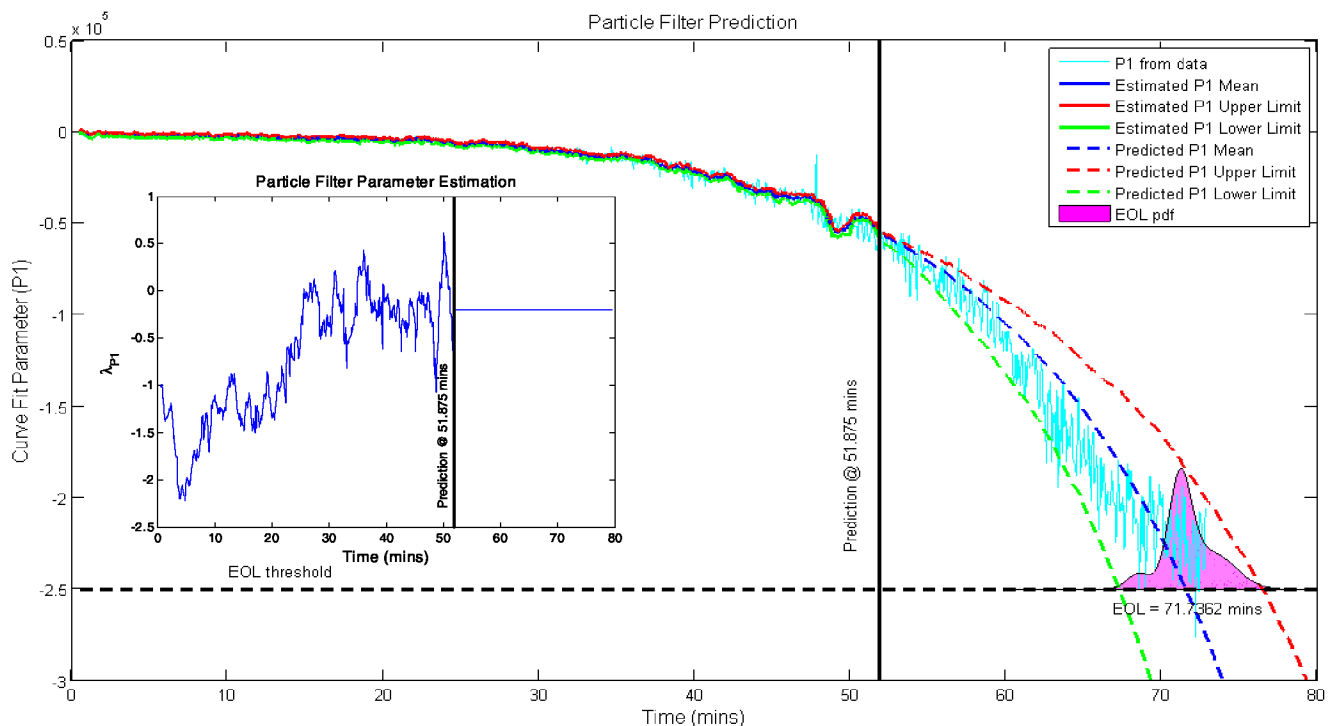
Figure 5 – Particle Filter Tracking and Prediction

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BIOGRAPHIES

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__Kai Goebel__ is a senior scientist at NASA Ames Research Center where he leads the Prognostics Center of Excellence (prognostics.arc.nasa.gov). Prior to that, he worked at General Electric's Global Research Center in Niskayuna, NY from 1997 to 2006 as a senior research scientist. He has carried out applied research in the areas of artificial intelligence, soft computing, and information fusion. His research interest lies in advancing these techniques for real time monitoring, diagnostics, and prognostics. He has fielded numerous applications for aircraft engines, transportation systems, medical systems, and manufacturing systems. He holds half a dozen patents and has published more than 75 papers. He received the degree of Diplom-Ingenieur from the Technische Universität München, Germany in 1990. He received the M.S. and Ph.D. from the University of California at Berkeley in 1993 and 1996, respectively.